

Doping

▶ A manufacturing process that adds free charge carriers (free **electron** or **hole**) into a pure semiconductor material to increase its conductivity .

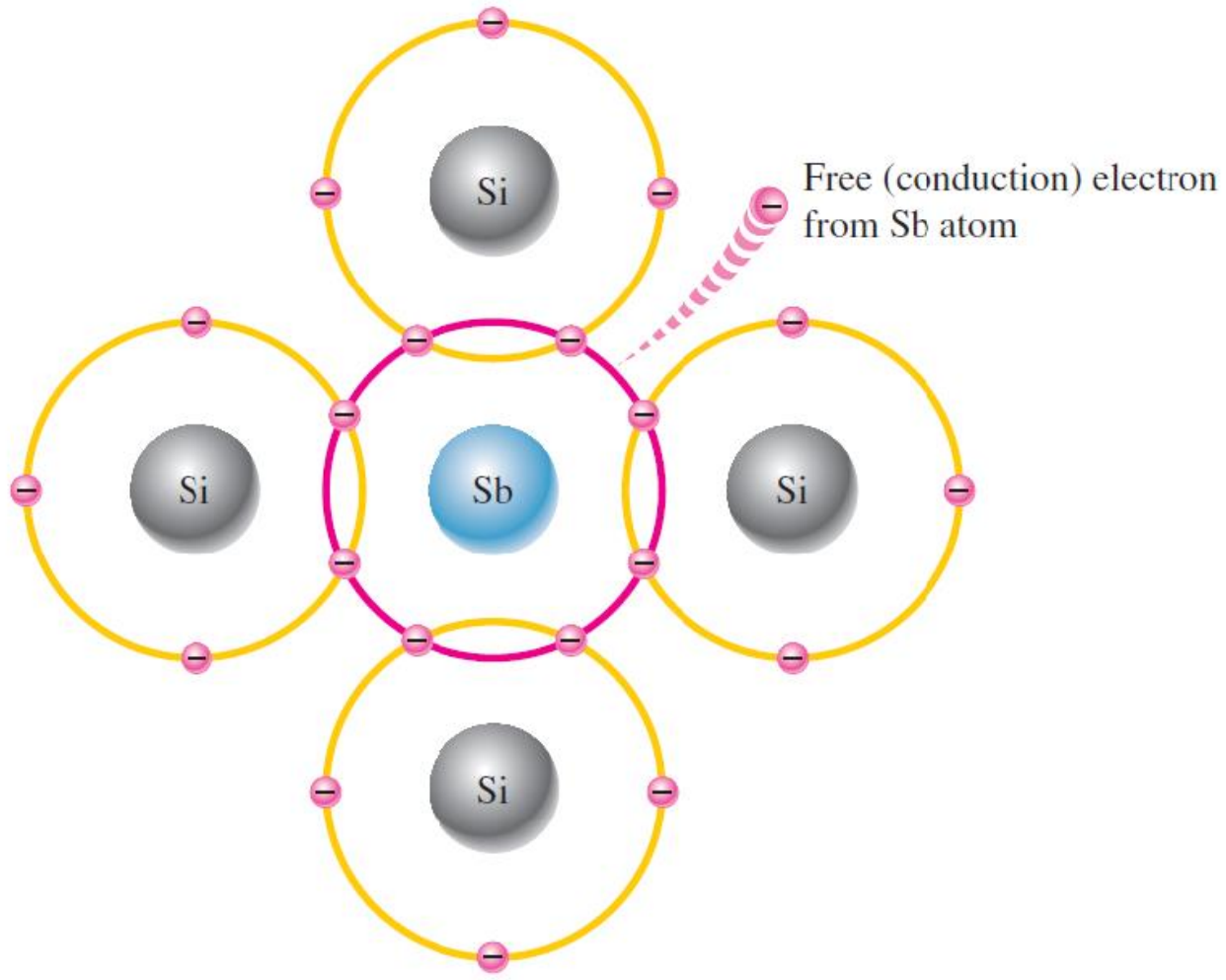
▶ Doping  **n**-type or **p**-type material

N - type semiconductor

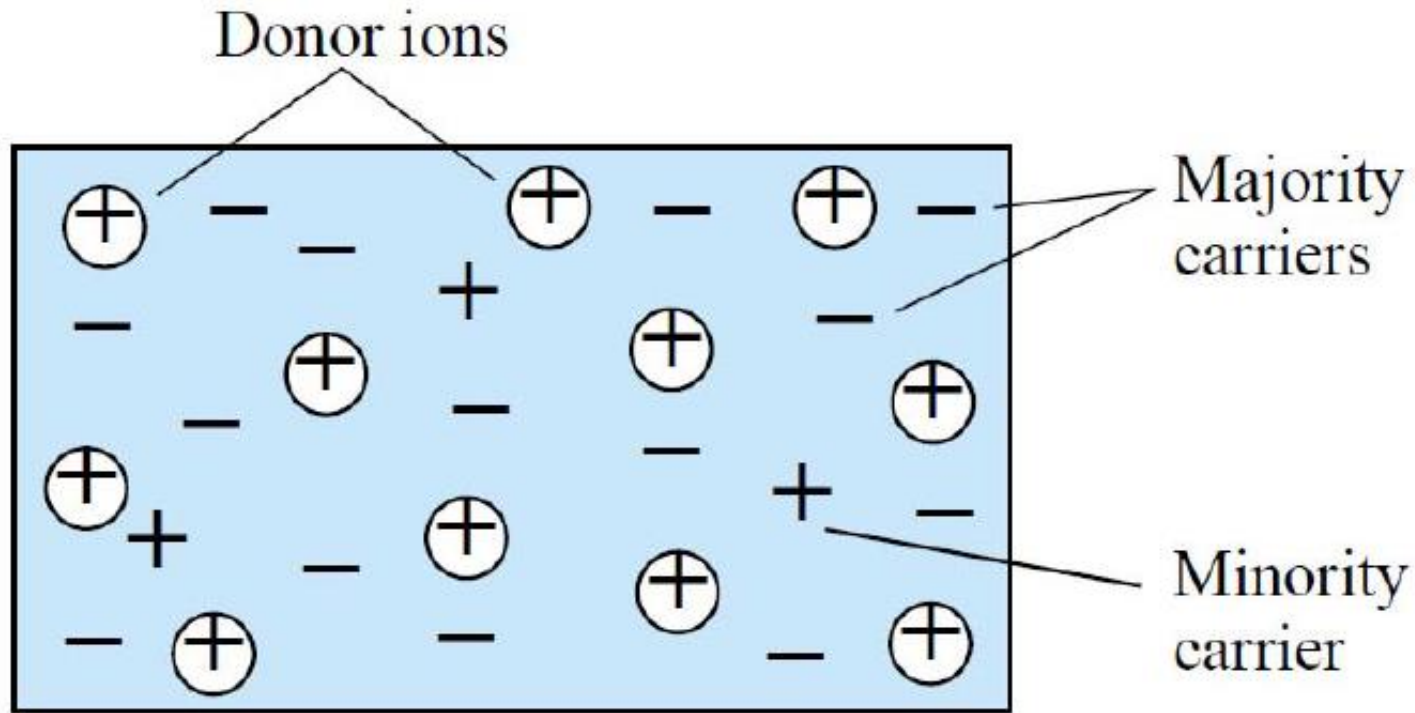
Sb (antimony) has five valence electrons and it is called a donor atom.

We add ($10^{15} - 10^{17}$) Sb atoms/cm³

At room temperature there is 5×10^{22} atoms/cm³ in pure Si .

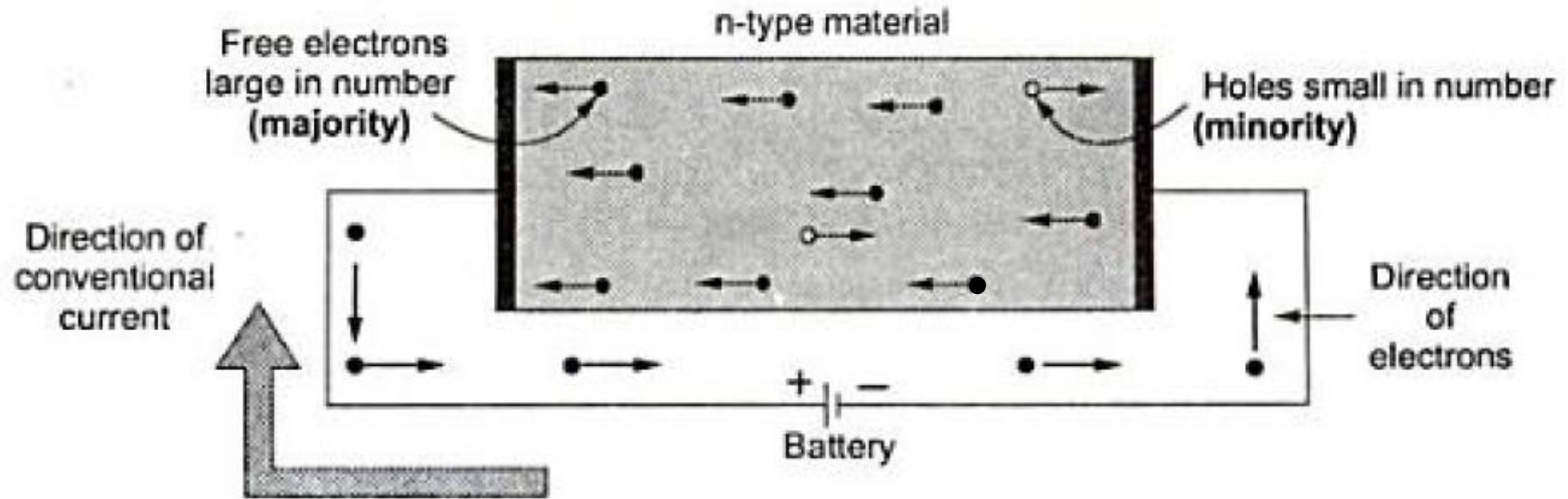


In the **n**-type material the free **electrons** are the **majority** and the **holes** are the **minority**.



n-type

Conduction in n-type material



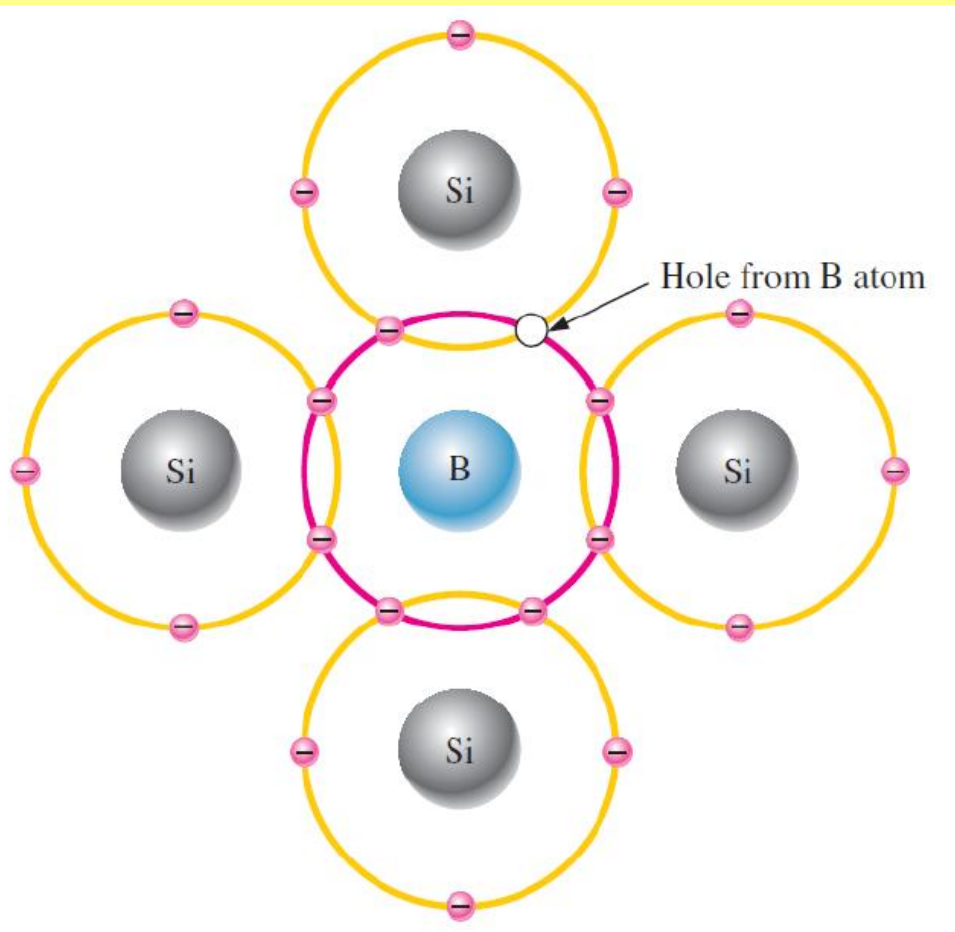
Conduction in n-type material

P - type semiconductor

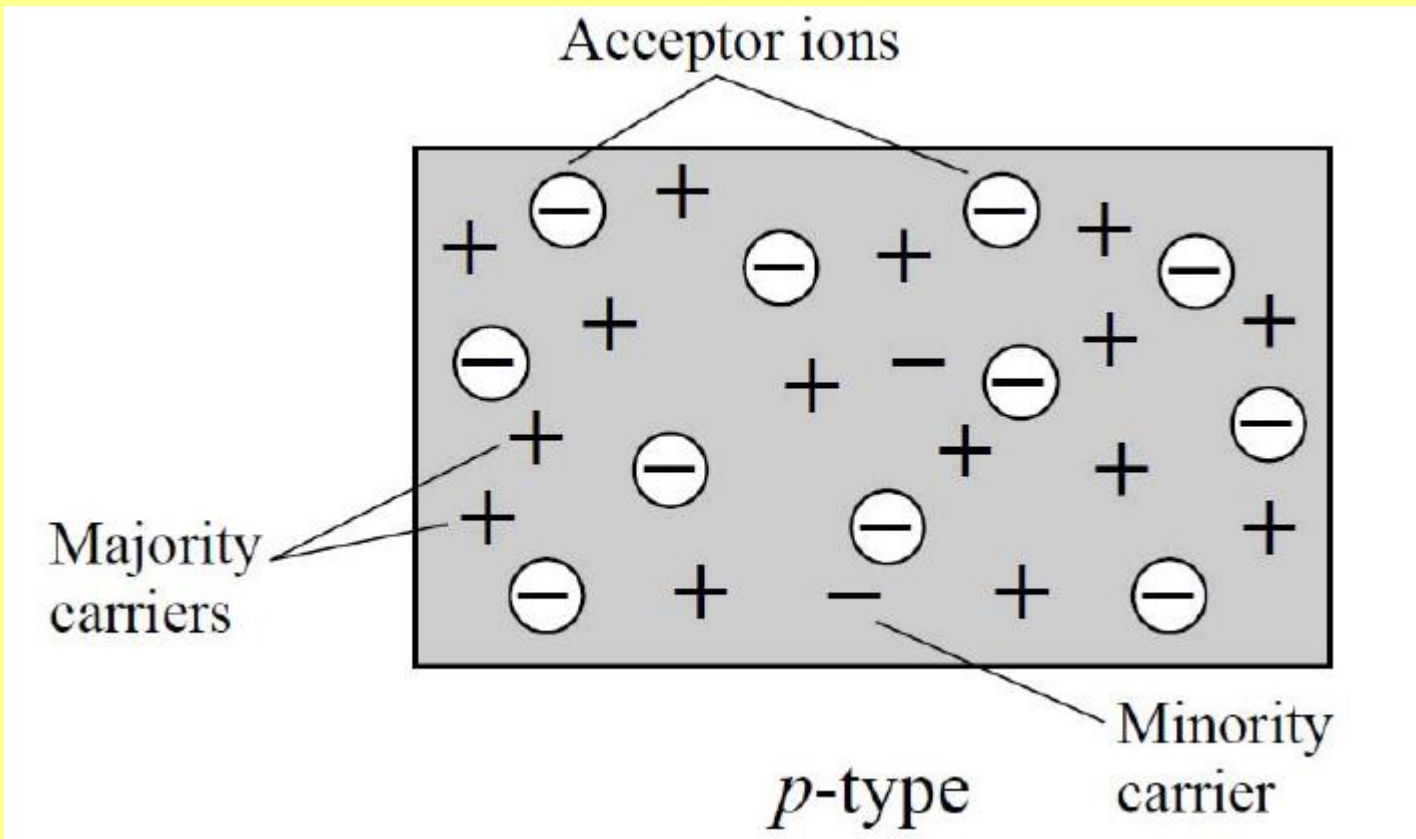
B (Boron) has three valence electrons (acceptor atom)

We add ($10^{15} - 10^{17}$) B atoms/cm³

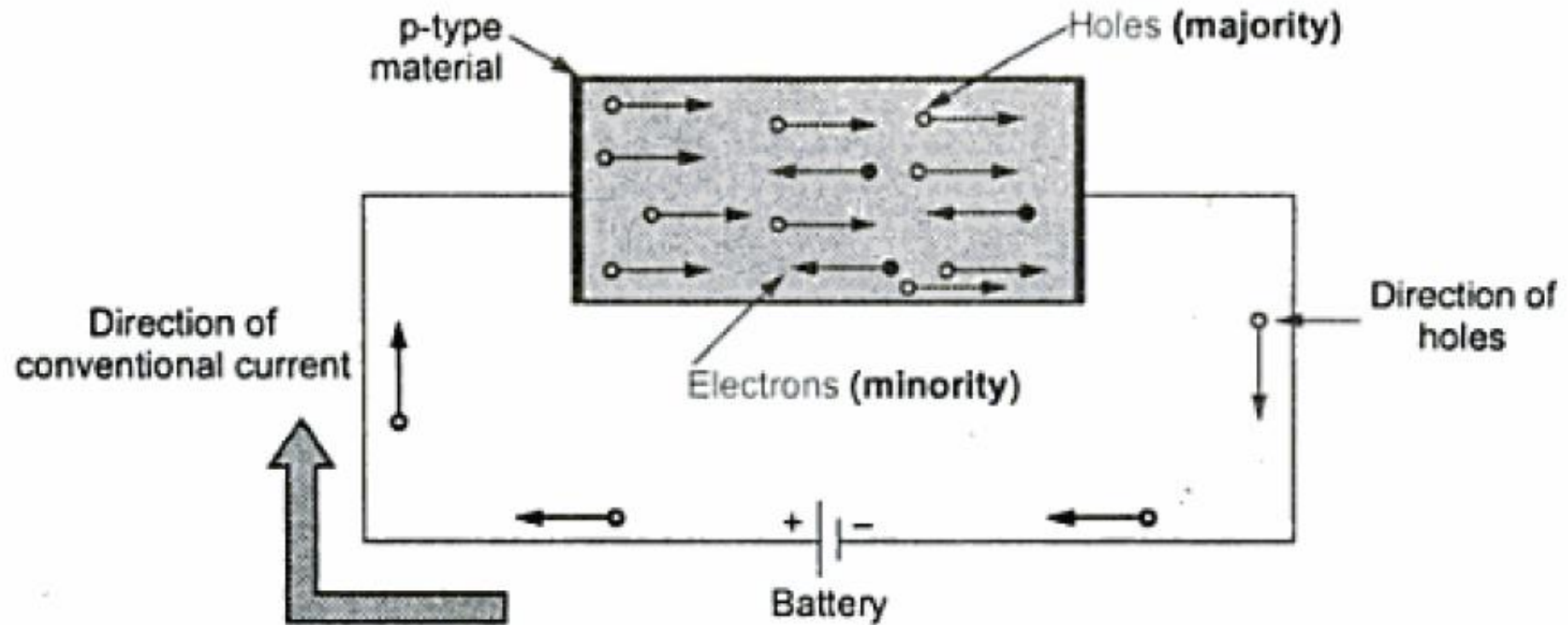
At room temperature there is 5×10^{22} atoms/cm³ in pure Si .



In the **p**-type material the **holes** are the **majority** and the free **electrons** are the **minority**.



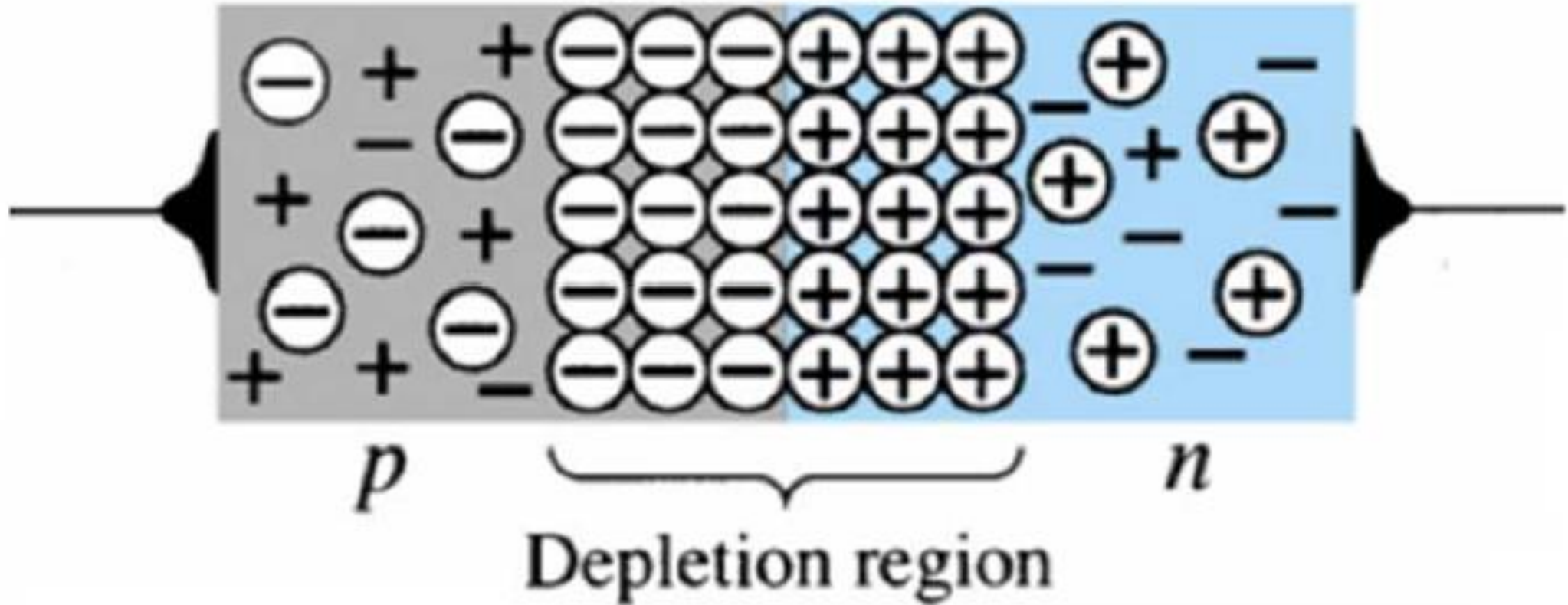
Conduction in p-type material



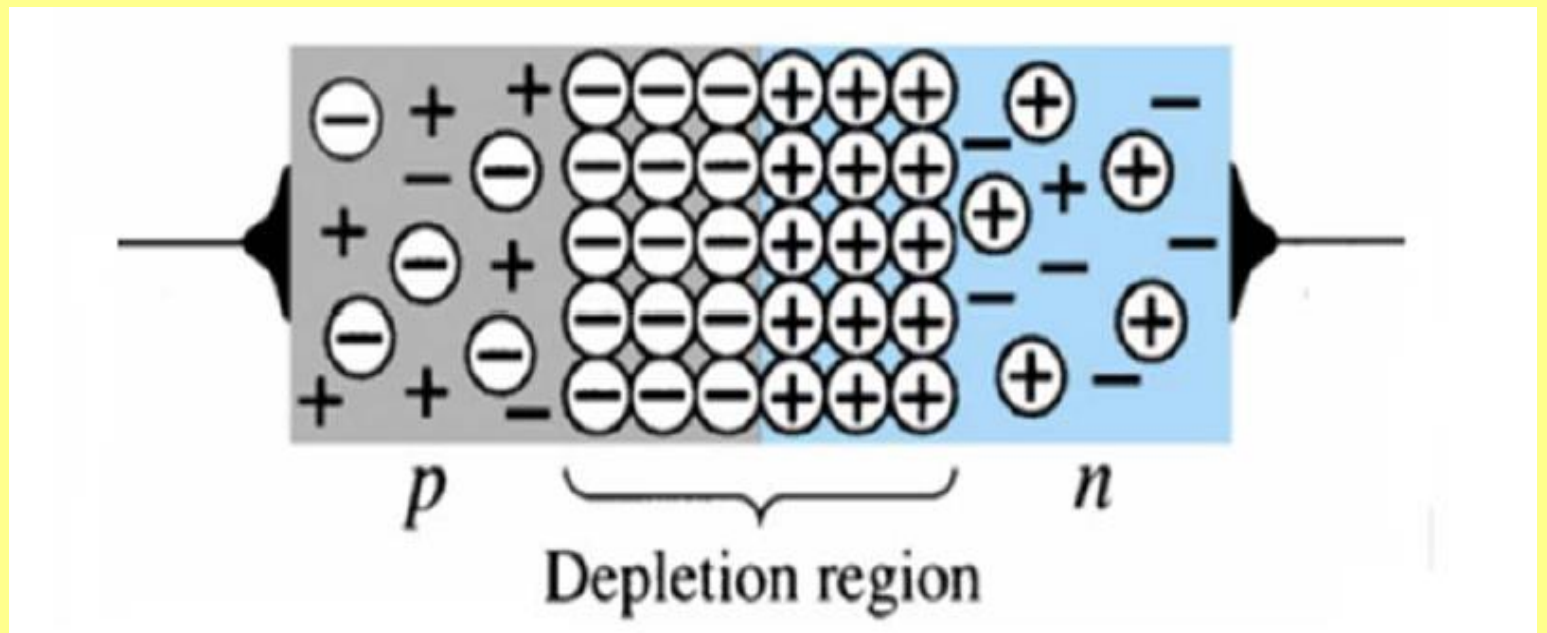
Conduction in p-type material

Pn junction

- ▶ The p-n junction is the basis for diodes, certain transistors, and other devices.



- 1) **Electrons** from the **n**-type material near the junction diffuse across the junction.
- 2) These **electrons** fill the **holes** in the **p**-type material adjacent to the junction.
- 3) As a result of **electrons** leaving the **n**-type material, donor ions are created on the n side of the junction.
- 4) When these **electrons** fill holes in the **p** side of the junction, acceptor ions are produced.
- 5) A wall of stationary **positive** ions is aligned with a wall of **negative** ions along the **n** and **p** sides of the junction.

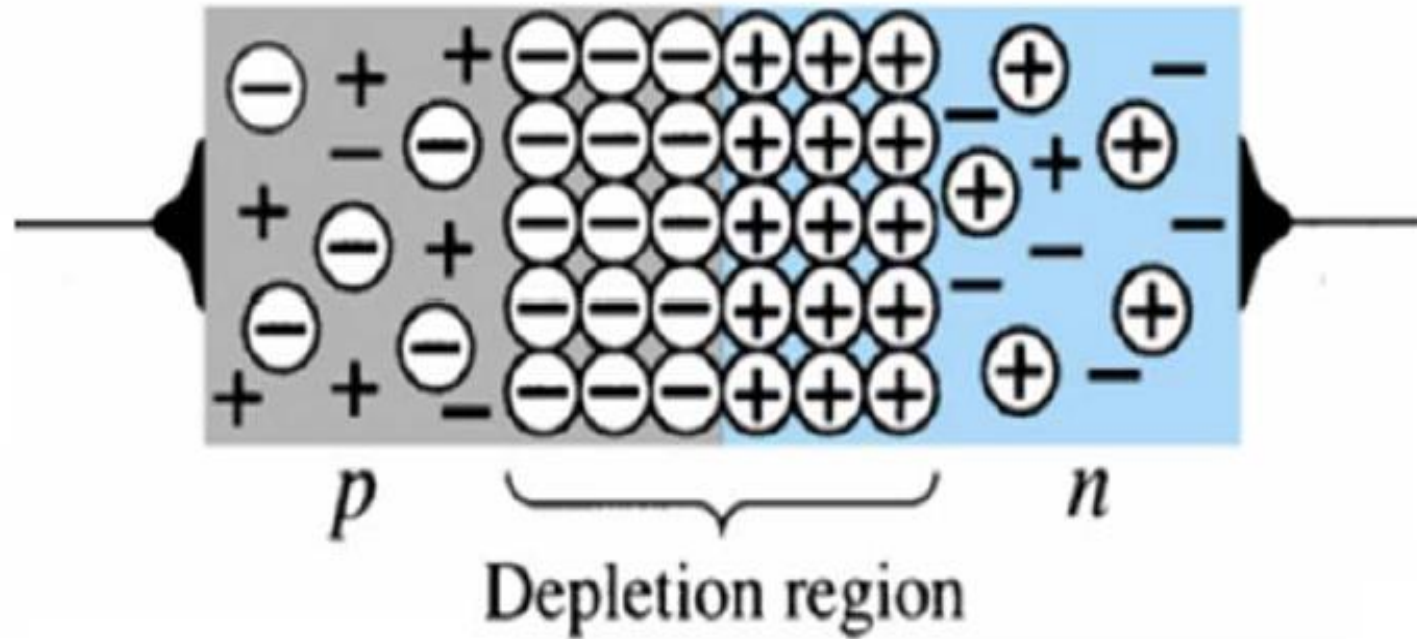


6) The space occupied between the ion walls is called **depletion region**.

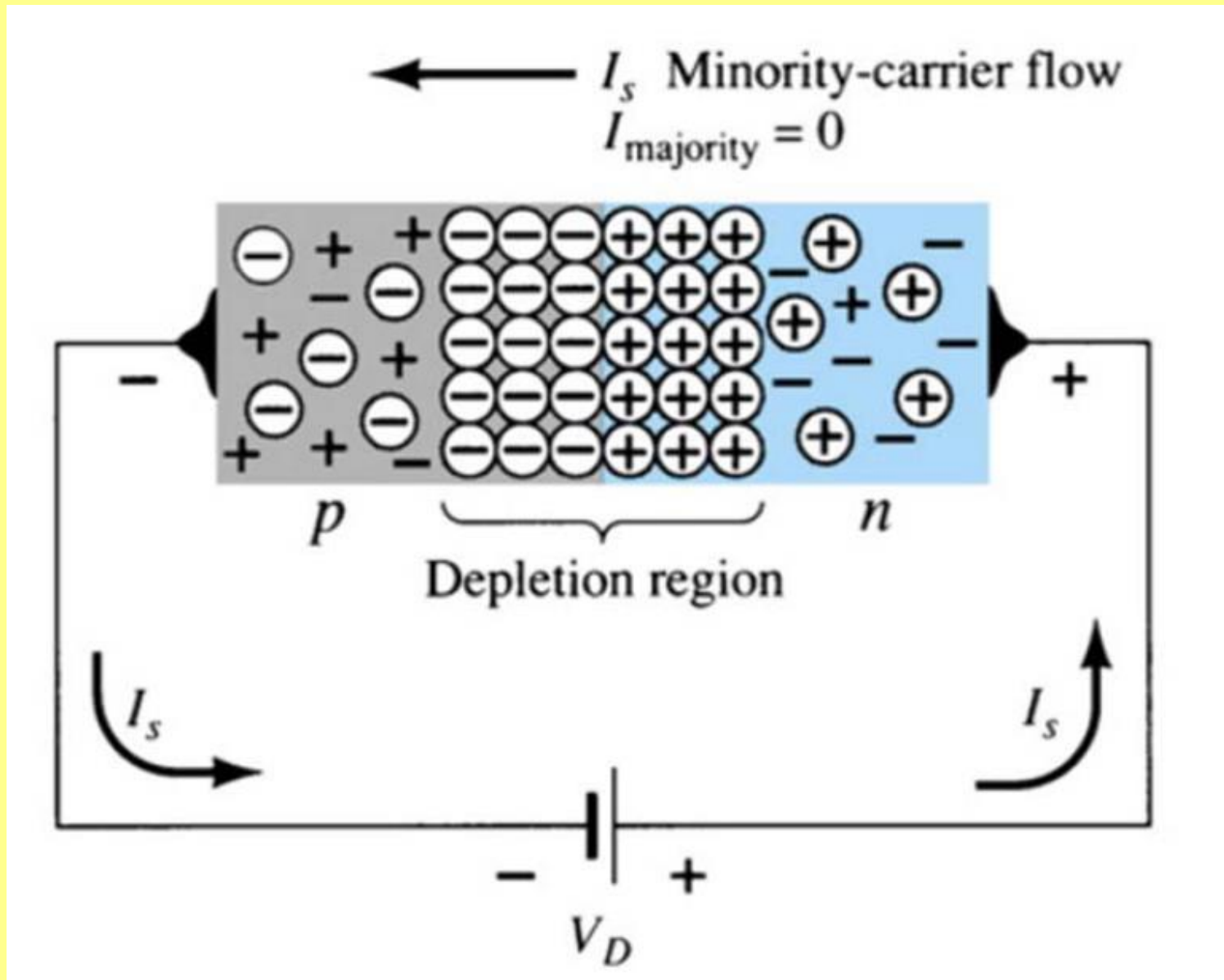
7)Whenever there exists a **positive** charge with respect to a **negative** charge , a voltage difference is set between charges ;(**Junction potential**, **Junction barrier**).

8) The **junction potential** acts as **potential barrier** that tend to prevent majority carriers from crossing the junction.

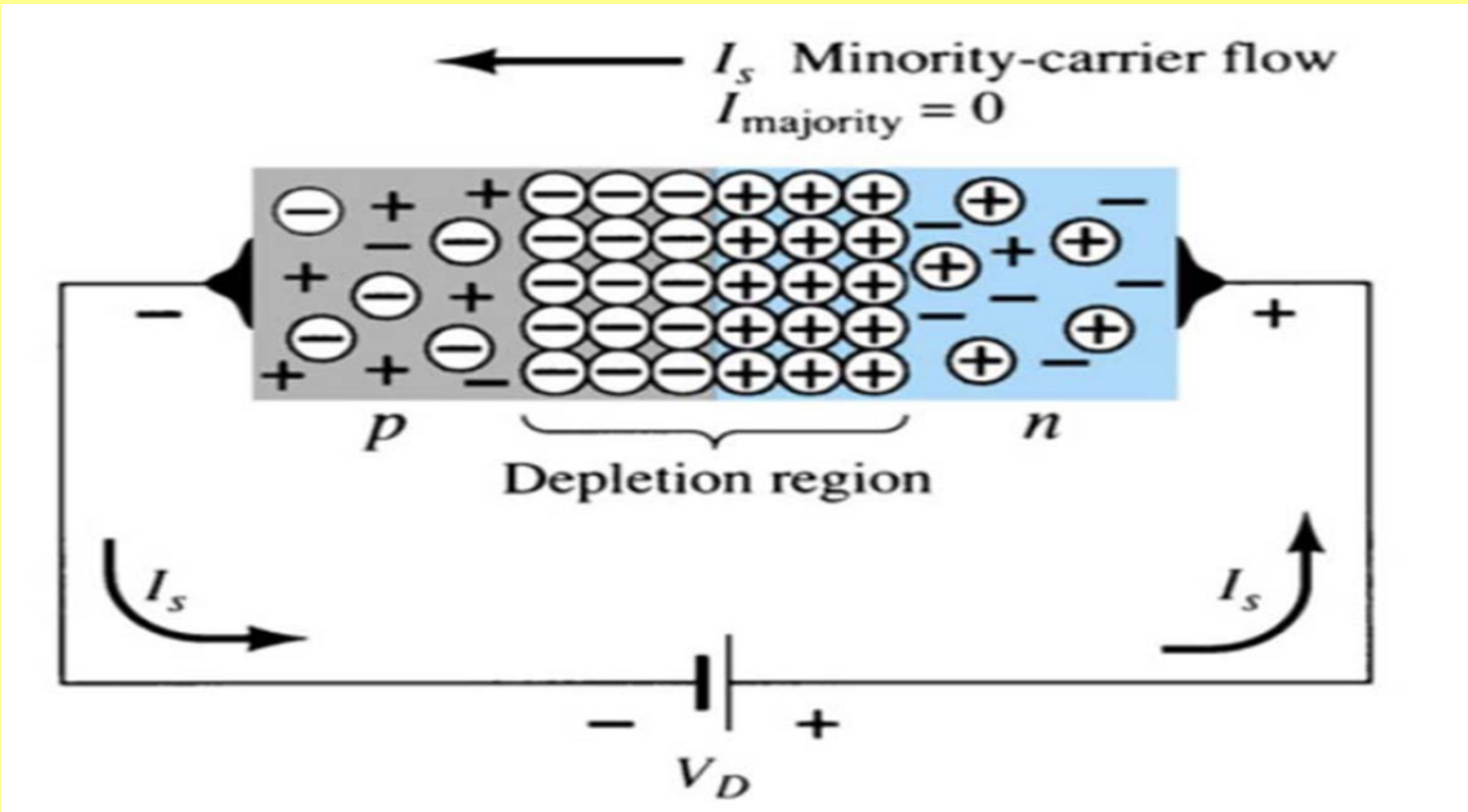
9) Minority carriers are aided by the **junction potential** .



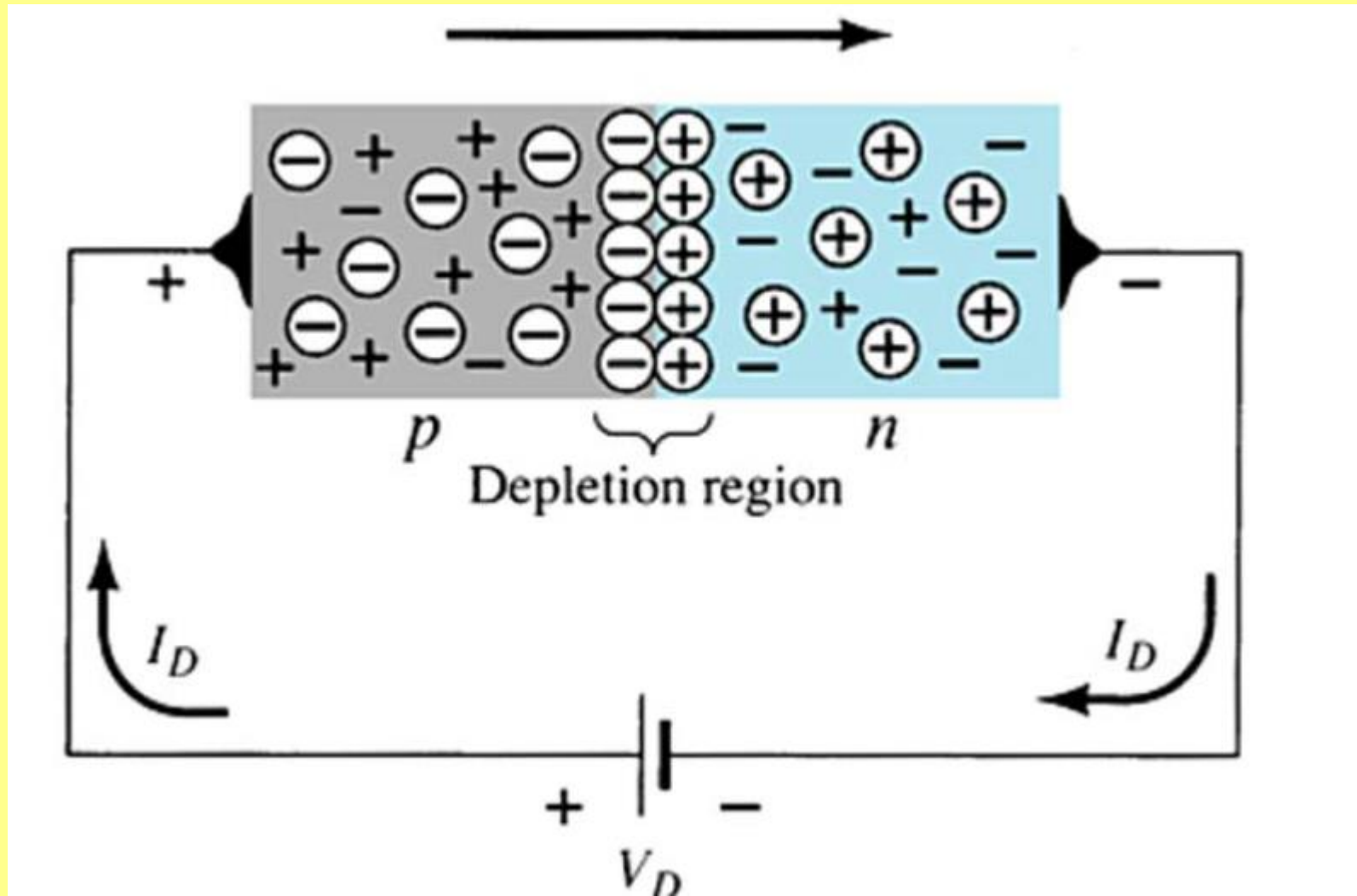
Reverse bias of a pn junction



- ▶ The reverse voltage causes the **depletion region** to **widen** .
- ▶ The **electrons** in the **n**-type material are attracted toward the **positive** terminal of the voltage source .
- ▶ The **holes** in the **p**-type material are attracted toward the **negative** terminal of the voltage source .



Forward bias of a pn junction



- ▶ The forward voltage causes the depletion region to narrow
- ▶ The electrons and holes are pushed toward the p-n junction
- ▶ The electrons and holes have sufficient energy to cross the p-n junction

